

Application No. 10/736,709
Amendment dated August 13, 2008
Reply to Office Action of April 14, 2008

Docket No.: 0630-1835P

REMARKS

Favorable reconsideration and allowance of the present application are respectfully requested in view of the following remarks. Claims 1, 2, 4, 7 and 11 have been amended. No new matter has been added. Claim 6 is currently cancelled and claims 3, 17-27 and 30-32 had previously been cancelled. Thus, claims 1, 2, 4, 5, 7-16, 28 and 29 are pending for consideration.

35 U.S.C § 103 REJECTION

Claims 1-2, 4-16, and 28-29 stand rejected under 35 U.S.C. § 103(a) as being unpatentable over Evans et al. (U.S. Patent No. 6,001,515, hereinafter "Evans") in view of Kando et al. (Japanese Patent Publication No. 09-318805, hereinafter "Kando"). Applicant respectfully traverses.

Independent claim 1 is allowable at least in that this claim recites a combination of elements, including, for example, "transferring the resist in the grooves of the second portion of the cliché on a blanket applied on a surface of the printing roll by contacting and rotating the printing roll with the second portion of the cliché, the printing roll corresponding to the second portion of the cliché" and "applying the resist transferred on the surface of the blanket of the printing roll on the etching object layer on the second area of the substrate." None of the cited references, singly or in combination, teaches or suggests at least these features of the claimed invention.

Accordingly, Applicant respectfully submits that claim 1 and claims 2, 4, 5, 7-10, 28 and 33-34, which depend directly or indirectly from claim 1, are allowable over the cited references.

Independent claim 11 is allowable at least in that this claim recites a combination of elements, including, for example, "transferring the resist filled in the groove of another of the divided areas of the cliché onto a surface of the blanket on the printing roll by contacting and rotating the printing roll with the another of the divided areas of the cliché corresponding to another of the divided areas of the substrate" and "applying the resist transferred on the surface of the blanket on the etching object layer on the area of the substrate corresponding to the

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another of the divided areas of the cliché." None of the cited references, singly or in combination, teaches or suggests at least these features of the claimed invention.

Accordingly, Applicant respectfully submits that claim 11 and claims 12-16 and 29, which depend directly or indirectly from claim 11, are allowable over the cited references.

Conclusion

All of the stated grounds of rejection have been properly traversed, accommodated, or rendered moot. Applicant therefore respectfully requests that the Examiner reconsider all presently outstanding rejections and that they be withdrawn. It is believed that a full and complete response has been made to the outstanding Office Action, and as such, the present application is in condition for allowance.

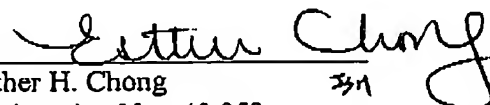
If the Examiner believes, for any reason, that personal communication will expedite prosecution of this application, the Examiner is invited to telephone Jun S. Ha, Registration No. 58,508, at (703) 205-8000, in the Washington, D.C. area.

Prompt and favorable consideration of this Amendment is respectfully requested.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. §§ 1.16 or 1.17; particularly, extension of time fees.

Dated: August 13, 2008

Respectfully submitted,

By 
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